Future Leaders Fellowships: Round 4 Sift Panel Membership

Panel Chairs
Nessa Carey, Independent
Gordon Harold, University of Sussex
Ruth Livesey, Royal Holloway, University of London
Barbara Mable, University of Glasgow
Peter Oakley, Independent
Tara Shears, University of Liverpool

Panel Members
Zulfiqur Ali, Teesside University
David Atkins, Congenica
Mimoun Azzouz, University of Sheffield
Elizabeth Baggs, University of Edinburgh
Caroline Barelle, Elasmogen Ltd
Tina Barsby, National Institute of Agricultural Botany
Judith Batchelor, Sainsburys
Gill Bates, QinetiQ
Ilaria Bellantuono, University of Sheffield
Jose Bengoechea, Queen's University of Belfast
Mark Birkin, The Alan Turing Institute
Ruth Blakeley, The University of Sheffield
Veronica Bowman, Defence Science and Technology Laboratory
Sarah Bridle, The University of Manchester
Philippa Browning, The University of Manchester
Alison Burdett, Sensium Healthcare
Julian Burke, Leica Microsystems
Ilaria Bellantuono, University of Sheffield
Neil Calder, Engineered Capabilities Ltd
Emilie Capulet, University of West London
Neil Champness, The University of Nottingham
Yimin Chao, University of East Anglia
Suzanne Clisby, Goldsmiths, University of London
Monica Craciun, University of Exeter
Joe Devine, University of Bath
Tao Dong, Oxford University
Ian Eggleston, University of Bath
Karen Faulds, University of Strathclyde
Edward Fieldhouse, The University of Manchester
Brian Gerardot, Heriot-Watt University
Valerie Gibson, University of Cambridge
Jennifer Gill, University of East Anglia
Mick Grierson, University of the Arts London
**Roving Panel Members**

Samantha Aspinall, University of Leeds  
Jonathan Legh-Smith, British Telecommunications  
Stefan Przyborski, Durham University  
Ian Rivers, University of Strathclyde  
Sara Shinton, University of Edinburgh  
Jonathan Wastling, Keele University

*Organisation of Panels will be responsive to the applications in each round. To ensure consistency some of the Future Leaders Fellowships College will be asked to join Panels for several rounds; others will be asked to join one panel per year, based on applicant demand.*